# CSW 2024 3-6 JUNE IN LUND, SWEDEN



## Preliminary program for CSW 2024 - Monday June 3rd

Time	МАб	MA7		
09.00				
10.00	Registi	ation		
10.00	Nanoscale Integration (tentative)	Advanced Characterization Methods (tentative)		
12.00	Short course	Short course		
12.00				
14.00	Registi	ation		
	No lunch wil			
	Aula Kårhuset			
44.00				
14.00	Opening Ceremony			
14.20				
14.20	Award Ceremony			
14.40				
14.40	Plenary I			
15.20	Powering up with Gallium Nitride technologie			
	Srabanti Chowdhury, Stanford			
15.20	Plenary II			
16.00	Connecting the Dots - Heterogeneous Integration, III-V, and the Future of Connectivity			
	Nadine Collaert, IMEC			
16.00				
18.00	Welcome Mingle			
	Pre-registratio	n is required		

## Preliminary program for CSW 2024 - Tuesday June 4th

Time	MA6	MA7
07.30		
08.30	Registration	
08.30	Session Gallium Oxide and related	Nano and Micro Optics
09.00	High performance gallium oxide devices, Uttam Singisetti	III-V nanowires for applications in quantum technologies and THz photodetection, Anna Fontcuberta e Morral
09.00	Contributed talks	Contributed talks
10.00	09.00 Ga2O3/GaN HETEROSTRUCTURE FOR DEEP UVC SENSING AND LED APPLICATIONS, Peter Ramvall	09.00 High-performance Micro-Size Light-Emitting and Detecting Diodes with Triangular shapes, Huabin Yu
	09.15 The epitaxial strain and stress relationships in the alpha and beta phases of (Al,Ga)2O3 and their effects onto phonon and electronic properties, <i>Mathias Schubert</i>	09.15 1.5µm SINGLE-PHOTON EMISSION FROM GaSb QUANTUM DOT EXCITED RESONANTLY WITH A SEMICONDUCTOR LASER, <i>Teemu Hakkarainen</i>
	09.30 HIGH-CRYSTALLINE QUALITY SI-DOPED $\beta$ -Ga2O3 WITH DIFFERENT SURFACE ORIENTATIONS BY HOT-WALL MOCVD, Daniela Gogova	09.30 EFFICIENT COLOR CONVERSION FROM COLLOIDAL QUANTUM DOTS EMBEDDED IN RESONANT CAVITY, Tae-Yun Lee
	09.45 Hf02/β-Ga2O3(–201) interface electrical properties after thermal treatment, <i>Karim Cherkaoui</i>	09.45 TUNEABLE STRUCTURAL COLORS FROM TiO2 MIE RESONATOR ARRAYS IN GLASS, Mikko Kjellberg
10.00		
10.30	Coffee Break	at Matteannexet
10.30	UWB materials	Lasers I
11.00	AIN substrates, Elke Meissner	Perspectives on the future of hybrid and regrown PCSELs, Weidong Zhou
11.00 12.00	Contributed talks	Contributed talks
12.00	11.00 Fully coalesced thin GaN growth on AIN substrates for AIN-based HEMTs by hot-wall MOCVD, <i>Minho Kim</i>	11.00 ENHANCED PERFORMANCE OF MULTIWAVELENGTH NANOWIRE LASERS, Mattias Jansson
	11.15 Polarization Induced Doping in N-Polar Graded AINDAIGaN Films Grown by Plasma-Assisted Molecular Beam Epitaxy, <i>Md Irfan Khan</i>	11.15 PHOTONIC CRYSTAL SURFACE-EMITTING LASERS FABRICATED BY DEEP-HOLE DRY ETCHING, Myeongeun Kim
	11.30 Fabrication at the speed of light: towards analyte-specific sensors made of diamond using UV laser	11.30 Selectively Grown Buried InGaAs/InP Quantum Wells on (001) SOI for Lateral Laser Diodes, Donghui Fu
	as energy source, Joana-Catarina Mendes	11.45 New contact approach for optical loss reduction in nano-ridge laser diodes grown on 300 mm silicon wafers, <i>Davide Colucci</i>
	11.45 THE ROLE OF GLASS-FRIT BONDING IN ACHIEVING CRACK-FREE GaN-HEMT TRANSFER TO SILICON CARRIER FOR DIAMOND GROWTH, <i>Rizwana Khanum</i>	
12.00		
13.00	Lunch at N	Matteannexet
13.00	THz Electronics	Wide Bandgap Photonics
13.30	Progress in Epitaxy of Ultra-High-Speed InP-based Transistors for Future Wireless Communication Systems, Takuya Hoshi	Progress in AlGaN-based Far-UVC LED Technologies and Their Applications, Michael Kneissl
13.30	Contributed talks	Nitride nanowire light emitting diodes: from single wire properties to device applications, Maria Tchernycheva
14.30	13.30 InP/GaAsSb DHBT Emitter Etching Process Optimization with a Simultaneous fT/fMAX = 451/914 GHz and 86% Device Yield, <i>Mojtaba Ebrahimi Marouf</i> i	
	13:45 Terahertz Oscillators Integrated with Multiple Resonant Tunneling Diodes into Cavity Resonator, Feifan Han	Contributed talks
	14.00 A 4.7-THz GaAs Schottky barrier diode mixer, Divya Jayasankar	14.00 Development of Rocksalt-structured-MgZnO-based UV-C Lamp Emitting in 190-220 nm Spectral Range, Kotaro
	14.15 Coherent Coupling in a Two-Dimensional Arrayed Resonant-Tunneling-Diode Terahertz Oscillator, Zhenling Tang	Ogawa 14:15 III-nitride-based photonic crystal surface-emitting lasers with UVC emission, <i>Dogukan Apaydin</i>

**TUESDAY JUNE 4TH** 

## Preliminary program for CSW 2024 - Tuesday June 4th

Time	MA6	MA7	
14.30 15.00	Coffee	e Break	
15.00 16.00	Postersession a	it Matteannexet	
	Wide Bandgap Devices HETEROGENEOUS INTEGRATION: BRINGING THE BEST MATERIAL FOR THE FUNCTION, Tomas Palacios	Integrated Photonics Semiconductor quantum dots for integrated photonics and long distance implementations, Simone Portalupi	
16.30 17.30	Contributed talks 16.30 Diamond growth for power and quantum device applications, <i>Okhyun Nam</i> 16.45 FIRST GAN DETECTOR ARRAY FOR HIGH ENERGY PROTON BEAM IMAGING, <i>Matilde Siviero</i> 17.00 Trap Characterization And Microwave Power Performance In Buffer-Free AlGaN/GaN-On-SiC MISHEMTs, <i>Amit Bansal</i> 17.15 Short-term reliability assessment of sub-micron thick AlN/GaN-on-Silicon HEMTs grown by MBE for RF applications, <i>Elodie Carneiro</i>	Contributed talks 16.30 INTEGRATED AMPLITUDE AND PHASE MODULATOR FOR FREE-SPACE OPTICAL COMMUNICATIONS ESTABLISHED IN THE LWIR ATMOSPHERIC WINDOW, Salvatore Pes 16.45 Compact light couplers for III-V membrane devices laterally grown on SOI, Zhaojie Ren 17.00 RIDGE QUANTUM CASCADE DETECTORS FOR FREE-SPACE OPTICAL COMMUNICATIONS ESTABLISHED IN THE LWIR, Nour Nawfal	

## Preliminary program for CSW 2024 - Wednesday June 5th

Time	MA6	MA7
07.30 08.30	Registration	
08.30 09.00	GaN and SiC Power Devices Breaking Barriers with GaN: Crystal Growth and Ultra-High-Pressure Annealing Strategies, <i>Michal</i> Bockowski	Epitaxial synthesis of nanomaterials Quantum Device Epitaxy, Erik Bakkers
09.00 10.00	Growth, defects and applications of 3C-SiC, Francesco La Via	Contributed talks 09.00 Template-Assisted Selective Epitaxy of InAs on W metal films, Johannes Svensson
	Contributed talks	09.15 Growth of GaSb nanowires revealed by environmental TEM, <i>Mikelis Marnauza</i>
	09.30 VERTICAL GAN PN DIODE WITH TRIPLE-ZONE EDGE TERMINATION USING STREAMLINED SINGLE- IMPLANT PROCESSING, Yu Duan	09.30 III-V NANOWIRES WITH LIGHT-ABSORBING/EMITTING PROPERTIES ON A 2-INCHI SI WAFER, <i>Keisuke Minehisa</i> 09.45 Charge carrier diffusion induced nanowire light-emitting diodes, <i>Yue Zhao</i>
	09.45 Fully-Vertical GaN-on-SiC Trench MOSFETs, Jialun Li	
10.00 10.30		
10.30 11.00	III-V HEMT & HBTS InGaAs HEMTs for Cryogenic Applications, Arnulf Leuther	Lasers II Temporal control of photonic-crystal surface-emitting lasers, <i>Takuya Inoue</i>
11.00 12.00	Contributed talks	Contributed talks
12.00	11.00 High fT and fmax of double δ-doped GaInSb channel HEMTs, Ryosuke Kouno	11.00 Type-I and type-II interband cascade lasers emitting below 3 µm, Maëva fagot
	11.15 INVESTIGATION OF ATOMIC LAYER ETCHING FOR FABRICATION OF InP HEMTS, Austin Minnich	11.15 OPTIMIZATION OF PL- AND LASING-WAVELENGTH DETUNING OF MEMBRANE LASERS FOR UNCOOLED OPERATION, Takuro Fujii
	11.30 Enhanced electron mobility in InSb/Ga0.22In0.78Sb composite channel HEMT structure, <i>Tomoki</i> Jinnai	11.30 Robust Measurement of Nanowire Laser Performance Across 8 Designs using Experimental Big-Data, Stephen Church
	11.45 TiW-based InP DHBT technology for next generation communication systems analog front-end integrated circuits, <i>Virginie Nodjiadjim</i>	11.45 Investigation of device length dependence of 1.55-µm-band QD-RSOA in threshold current of SiPh-based heterogeneous tunable laser, <i>Taisuke Matsuki</i>
12.00 13.00	Lunch at l	Matteannexet
13.00 13.30	GaN HEMTs Advances in Field Control and Exploitation in III-N Devices, <i>Patrik Fay</i>	Nanowires and Advanced Characterization Nanoscale compositional and luminescence fluctuations in Zn-doped GaAs nanowires, Stephen Church
13.30 14.30	Contributed talks	Contributed talks
14.50	13.30 BUFFER ENGINEERING OF ALGAN CHANNEL TRANSISTORS ON SILICON GROWN BY MOLECULAR BEAM EPITAXY FOR HIGH VOLTAGE APPLICATIONS, Antoine BARBIER-CUEIL	13.30 ANNEALING EFFECT ON GaAs AND GaNAs NANOWIRES AT VARIOUS TEMPERATURES, HIDETOSHI HASHIMOTO
	13:45 GaN HEMT using partial high-k films at G-D spacing to improve breakdown voltage, Yasuyuki Miyamoto	13:45 Visualizing the Vapor-Solid-Solid Growth of Wurtzite GaP Nanowires, <i>Tianyi Hu</i> 14.00 SINGLE INDIUM PHOSPHIDE NANOWIRE DIODES AS ULTRAHIGH-RESOLUTION DETECTORS FOR IMAGING X-RAY AND OPTICAL FOCI, <i>Nils Lamers</i>
	14.00 High threshold voltage p-GaN/p-AlGaN/AlGaN/GaN HEMT, <i>Min Gi Jeong</i> 14.15 CONTROL OF COMPOSITION AND CHANNEL-BARRIER INTERFACE SHARPNESS IN MOCVD GROWN	14.15 STRAINED CORE/DUAL-SHELL NANOWIRES: THE DIFFERENT INTERFACE ROLES AND THEIR IMPORTANCE FOR APPLICATIONS OF GAAS ACROSS NEAR-INFRARED, Xiaoxiao Sun
	HIGH-AI CONTENT AIGaN/GaN HEMTS, Alexis Papamichail	

## Preliminary program for CSW 2024 - Wednesday June 5th

Time	MA6	MA7
14.30		
15.00	Coffee Break	at Matteannexet
15.00		
16.00	Postersession	at Matteannexet
16.00		Heterostructures and interfaces
16.30		Three-Dimensional Monolithic and Heterogeneous Integration of Two-Dimensional Materials, Saptarshi Das
16.30		Contributed talks
17.30		16.30 NANOCLUSTERS IN HIGH-MOBILITY ULTRAFAST INGAAS PHOTOCONDUCTORS ON InP, Steffen Breuer
		16.45 INVESTIGATION OF INP-SI INTERFACE BAND STRUCTURE USING DENSITY FUNCTIONAL THEORY, Kyro Odyssefs
		Kosmatos
		17.00 III-V semiconductor epitaxy based on machine learning and in-situ feedback control, Chao Zhao
		17.15 OPTICALLY ACTIVE InGaAs AXIAL NANOWIRE HETEROSTRUCTURES FOR QUANTUM INTEGRATED PHOTONIC CIRCUITS, Hyowon Jeong
19.00		
	Conference Dinner at Grand Hotel	
	Pre-registrati	on is required

### Preliminary program for CSW 2024 - Thursday June 6th

**THURSDAY JUNE 6TH** 

Time	MA6	MA7
07.30		
08.30	Regist	ration
08.30 09.00	Optical Detectors and Solar 2D Materials optics, <i>Elisa Antolín</i>	Neuromorphic Computing Analog bilayer memristors for neuromorphic computing, Saketh Mamidala Ram
09.00	Contributed talks 09.00 Sustainable high efficiency multi-junction nanowire solar cells, <i>Mariia Shcherbakova</i> 09.15 Monolithically integrated InAs/InGaAs dual-band infrared photodetector, <i>Seungwan Woo</i> 09.30 DYNAMICS OF HOT CARRIERS IN InGaAs NANOWIRES MONOLITHICALLY GROWN ON SILICON, <i>Hamidreza Esmaielpour</i> 09.45 Multijunction-type PIN photodetector with pinhole reflection for optical communication applications, <i>Toshimasa Umezawa</i>	Contributed talks 09.00 Optoelectronic Nanowire Neuron, <i>Thomas Kjellberg Jensen</i> 09.15 Semiconductor-Oxide Interfaces of InAs-based Ferroelectric and Memristive Devices, <i>Wenshan Chen</i> 09.30 III-V NANOWIRE BASED NEUROMORPHIC NANOPHOTONIC DEVICES, <i>Vidar Flodgren</i> 09.45 Investigation of energy barrier height and polarization-dependent conduction characteristics in ferroelectric capacitors on Indium Arsenide, <i>Hannes Dahlberg</i>
10.30	Coffee Break	at Matteannexet
10.30 11.00	AlScN and ferroelectrics Thermal conductivity of III-Nitrides, Plamen Paskov	III-V Quantum and Nanowire Devices TBD, Cezar Zota
11.00 12.00	Polarization order and emerging device applications of wurtzite ferroelectrics, Zetian Mi	Contributed talks 11.00 Investigation of Noise Performance in InP HEMTs with Varying Indium Channel Composition from 80 K to 300 K, Junjie Li
	Contributed talks 11.30 MOLECULAR BEAM EPITAXY OF (AI,Sc)N NANOWIRES FOR PIEZOELECTRIC ENERGY HARVESTING, Philipp John 11.45 TERAHERTZ OPTICAL HALL EFFECT IN AIScN/GaN AND AIYN/GaN HEMT STRUCTURES, Vallery Stanishev	<ul> <li>Junife Li</li> <li>11.15 Gate-Controlled Near-Surface Josephson junctions, Louise Olausson</li> <li>11.30 Demonstration of vertical resonant tunneling field-effect transistor using InGaAs/GaAs super lattice nanowires, Yoshiki Tai</li> <li>11.45 Enhancing III-V Nanowire MOSFET RF Performance through Optimized Gate Resistance, Marcus Sandberg</li> </ul>
12.00 13.00	Lunch at M	Matteannexet
13.00 13.30	Oxide Enabled Electronics TBD	Semiconductor nanostructures, surfaces, and synchrotron studies Exploring semiconductor nanostructures with synchrotron nanobeams, <i>Gema Martinez Criado</i>
13.30 14.30	Contributed talks         13.30 Lattice-matching epitaxy of rutile-type GexSn1-xO2 alloy film on TiO2 substrate for device applications, <i>Hitoshi Takane</i> 13:45 SOLID-PHASE-EPITAXY OF RUTILE-GeO2 IN MOLECULAR BEAM EPITAXY (MBE), <i>Wenshan Chen</i> 14.00 Non-volatilely Reconfigurable Frequency Modulation with a III-V Ferroelectric Transistor, <i>Zhongyunshen Zhu</i> 14.15 DEVELOPMENT OF AN ITO-BASED FERRO-ELECTRICAL MOSFET, <i>Karl-Magnus Persson</i>	Contributed talks         13.30 SURFACE PROPERTIES OF P-GAN AND INTERACTION WITH NICKEL, Mikko Miettinen         13:45 Bismuth-trimer adlayer on In- and Sb- terminated InSb(111) surfaces, Rohit Yadav         14.00 Quasi-ALE process for GaN: High etching rate without compromising the surface roughness, Paula Mouriño-Miñambres         14.15 Evaluating Atomic Layer Etching: Analytical Approaches to Ion Energy Control for semiconductor devices, Oscar Danielsson
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## Preliminary program for CSW 2024 - Thursday June 6th

Time	MA6	MA7
14.30 15.00	Coffee Break a	at Matteannexet
15.00 15.30	Quantum Dots and Advanced Characterization Growth and properties of GaAs quantum dots for quantum science and technology, Armando Rastelli	UV LEDs and mLEDs UV LEDs/micro-LEDs for optical wireless communications, <i>Martin Dawson</i>
15.30 16.30	Contributed talks 15.30 In-situ OBSERVATION OF INAS/GaAs QUANTUM DOTS USING THE MAGNIFICATION INFERRED CURVATURE METHOD, Jinkwan Kwoen 15.45 IN-SITU SYNTHESIS OF FexPy NANOPARTICLES, Azemina Kraina 16.00 Monodisperse InAs QDs investigation through Atom Probe Tomography, Binita Tongham 16.15 THz electron paramagnetic resonance ellipsometry for defect characterization in semiconductor materials: Bloch equations and superconvergence rules in the frequency-dependent magnetic susceptibility, Mathias Schubert	Contributed talks 16.30 SCALABLE TOP-DOWN FABRICATION OF (IN,GA)N NANOWIRES FROM EPITAXIAL LAYERS, Lutz Geelhaar 16.45 OPTICAL INVESTIGATIONS OF NANO-LEDS BASED ON MICRON SIZED III NITRIDE PLATELETS, Anders Gustafsson 17.00 InGaN platelets for red micro LEDs, Magnus Heurlin